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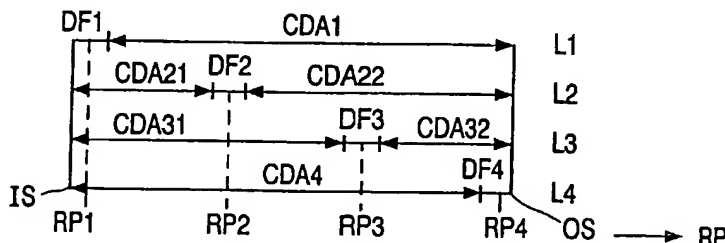
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(54) Title: DEFECT AREA MANAGEMENT



are different.

(57) Abstract: A multi-layer optical writable disc (D) comprises at least two layers (L1, L2, ...) and at least two defect management areas (DF1, DF2, ...). A first defect management area (DF1) is positioned on a first layer (L1) of the at least two layers at a first radial position (RP1), and a second defect management area (DF2) is positioned on a second layer (L2) of the at least two layers at a second radial position (RP2). The first radial position (RP1) and the second radial position (RP2)

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